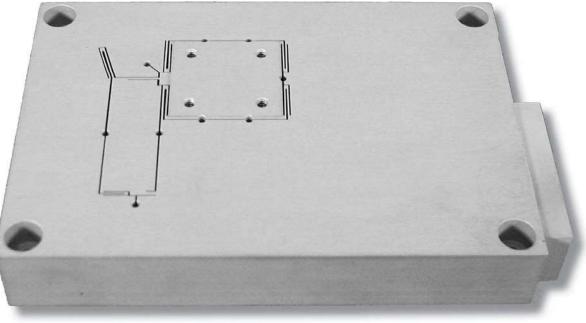
Features

- Long range single axis motion: 200 μm
- Less than 5 nm out of plane motion
- ▶ Low profile design
- > pico sensor technology
- Closed loop control

Typical Applications

- ► Surface metrology
- Wafer scanning and alignment
- Optical alignment



Nano-LR200 (1-axis) constructed from aluminum.



Product Description

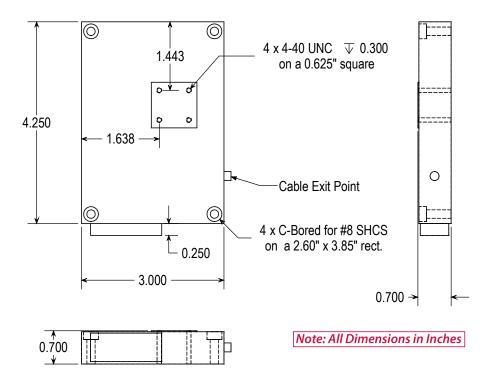
The Nano-LR200 is designed to provide long range, single axis translation with an absolute minimum of out-of-axis motion. The unique design of the Nano-LR200 produces less than 5 nm of out-of-plane motion; measured over the entire moving platform throughout the 200 μ m range of motion. The Nano-LR200 sets the highest level of single axis precision and positioning performance. Internal position sensors utilizing proprietary **pico** technology provide absolute, repeatable position measurement with sub-nanometer accuracy under closed loop control. The Nano-LR200 is ideally suited for applications that require extreme parallelism, such as metrology, AFM and MEMS.



Technical Specifications

Range of motion (X) 200 μm
Resolution0.4 nm
Resonant Frequency 500 Hz ±20%
Resonant Frequency (100g load) 200 Hz ±20%
Stiffness0.2 N/µm
θ_{roll} , θ_{pitch} (typical)
$\theta_{y_{aw}}$ (typical) $\leq 0.3 \ \mu rad$
Recommended max. load (horizontal)*0.5 kg
Recommended max. load (vertical)*0.2 kg
Body MaterialAl
Controller Nano-Drive®

* Larger load requirements should be discussed with our engineering staff.



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